



Descripción

Aerating additive for making mortars more workable. PLAIS added to the mixing water provides a wide plasticity to mortar and concrete, increasing its manageability by allowing reduced water mixing.

Dosages:

Normal: 1 l. / 2500 kg of cement.

Super: is diluted with water in 1:3 ratio, using 20 cc of dilution per sack of cement. 1 l / 10,000 kg of cement.

Aplication

Plais N is used when it's necessary to improve the workability of mortar and concrete, to slightly reduce the water/cement ratio, to achieve a better finish of the molded parts, to increase mechanical strength. Cohesion increases avoiding segregation, increases the hardened mortar's resistance to frost. Does not change the setting and hardening times.

Surface preparation

Not applicable.

Modes of application

Mix the package contents for the correct homogenization of the product.
-Plais N is added to the mixing water in the ratio of 1L per 2,500 kg. Of cement.
It is recommended to add 10 cm³ of PLAIS N to mixing water for every 25 kg

of cement.

- It thus enables to reduce the A/C ratio so as to obtain an improved finish for moulded pieces by increasing their mechanical resistance.

Clean up

With plentiful clean water

Data sheet

Colour/sdark brown

Density1,03 Kg/L. (+-) 0,05 g/cm³.

PH7 ± 1

Solid content> 25%

Performance

According to use

Storage

During 3 years in their original packagings, properly closed in a dry and cool area, and at temperatures above 4 ° C.

Security

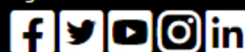
Supplementary information:

EUH208: EUH208:Contains 5-chloro-2-methyl-4-isothiazolin-3-one [EC no. 247-500-7] and 2-methyl-2H-isothiazol-3-one [EC no. 220-239-6] (3:1). May produce an allergic reaction.



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EUH210: EUH210:Safety data sheet available on request.



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